iemn Institut d'Electronique, de Microélectronique et de Nanotechnologie

## Coupling of electronic and mechanical degrees of freedom in quantum nanostructures

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RENATECH

#### Introduction

- From the electronic structure of atoms to the vibrational spectrum of molecules
  - coupling of electronic and vibrational degree of freedom ⇒ Raman spectroscopy

Emission and Absorption Spectra for Hydrogen





http://dosxx.colorado.edu/~bagenal/1010/SESSIONS/13.Light.html



#### Introduction

- From the electronic structure of atoms to the vibrational spectrum of molecules
- Actual nanostructures closer to single molecules ⇒ do they show similar behavior?
  - e.g. carbon nanotubes





S. Sapmaz et al., Nano Lett. 6, 1350 (2006)

#### Introduction

- Electronic transport
  - resistance (conductance)
    of a conductor
- Electrons are quantum particles
  - How quantum mechanics influences electronic transport?
  - What is a nanostructure in terms of quantum transport?
- Motion of the atoms of the conductor
  - microscopically: electron-phonon coupling
  - nanostructures: nanoelectromechanical systems (NEMS)
  - New behavior in quantum nanostructures?





## Outline

- part 1: electronic transport in quantum nanostructures
  - length and energy scales of quantum electronic transport
  - Coulomb blockade and quantum dots
  - fabrication of nanostructures and measurement techniques
- part 2: coupling of electronic and mechanical degrees of freedom



### Length and energy scales of quantum electronic transport



#### Lengths scales for electronic transport

- Classical transport (Drude)
  - electron = particle (wave packet)
  - independent scattering (incoherent)
  - no interactions

$$j = \sigma E$$
$$\sigma = \frac{n e^2 \tau_{tr}}{m}$$



## Lengths scales for electronic transport

- Fermi wave length  $\lambda_{_{\rm F}}$ 
  - only electrons at  $E_{F}$  participate to the transport
- Mean free path  $\boldsymbol{\ell}_{\boldsymbol{\rho}}$ 
  - mean distance between two scattering events

ł,

- Phase coherent length  $\ell_{d}$ 
  - memory of the phase
- Classical limit:

 $-\lambda_{\mu} < \ell_{e}$  and  $\ell_{h} < \ell_{e}$ 



### **Energy scales**

- Level spacing  $\Delta = E_{i+1} E_i$ 
  - energy quantization
- Charging energy  $e^2/C$ 
  - effect of electron-electron interactions
- Thermal energy  $k_{\rm B}T$ 
  - energy averaging
  - decoherence (phonons, electron-electron interactions)





Length and energy scales in nanostructures



#### Quantum confinement

- Size of the system *L*
- $L \sim \lambda_{F} \Rightarrow$  quantum confinement (conductance quantization, nanophysics)
  - density of states in confined systems:





#### **Ballistic transport**

- Size of the system *L*
- $L < \ell_e \Rightarrow$  ballistic transport



H. van Houten *et al.*, in Physics and Technology of Submicron Structures (Springer, Berlin, 1988)



#### Coherent transport

- Size of the system L
- $L < \ell_{g} \Rightarrow$  interferences between electron wave functions (mesoscopic transport)





⊁

Coulomb blockade and quantum dots



#### Coulomb blockade: the single electron transistor



 $-Ne=Q_g+Q_L+Q_R$  $C = C_L + C_R + C_g$  $V_{g} = \frac{Q_{L}}{C_{L}} - \frac{Q_{g}}{C_{g}} = \frac{Q_{R}}{C_{R}} - \frac{Q_{g}}{C_{g}}$  $E_{ch}(N, V_g) = \frac{Q_L^2}{2C_L} + \frac{Q_R^2}{2C_R} + \frac{Q_g^2}{2C_g}$  $\approx \frac{\left(Ne - C_g V_g\right)^2}{2C}$ 

#### Coulomb blockade: the single electron transistor E<sub>ch</sub> gate $\Gamma_{\rm s}$ $\Gamma_{\rm d}$ dot source drain *N* = 1 $\Delta E_c$ *N* = 2 $N \neq 0$ Ν tunnel barriers 3 $C_{\rm I}$ 2 $C_{\rm R}$ Ν 1 $C_{\rm g}$ $V_{_{\rm g}}$ emr 2 0 1 $C_a V_a /$ le/ Institut d'Electronique, de Microélectronique et de Nanotechnologie UMR CNRS 8520

## Confinement energy: the quantum dot

 Non-interacting particles: interference between reflected electron paths (Fabry-Perot) ⇒ discrete spectrum





#### Quantum dot = tunable artificial atom

• From the single electron transistor to the quantum dot





$$E_{ch}(N) \approx \left(N + \frac{1}{2}\right) E_{C}$$
$$E_{C} = \frac{e^{2}}{C} \approx \frac{e^{2}}{\varepsilon_{0} \varepsilon_{r} L}$$

 $\varepsilon_r = 1 \Rightarrow E_c \approx 200 \text{ meV pour } L = 100 \text{ nm}$ ( $\varepsilon_r < 1$  in usual semiconductors)

$$\Delta \approx \frac{\pi^2 \hbar^2}{m L^2}$$

 $m = 9,1 \times 10^{-31} \text{ kg}$   $\Rightarrow \Delta \approx 75 \ \mu\text{eV} \text{ for } L = 100 \ \text{nm}$  $(m_{\rho}^{*} < m_{\rho} \text{ in usual semiconductors})$ 

#### Electronic transport through a quantum dot

• Spectroscopy of electronic states





#### Electronic transport through a quantum dot

• Spectroscopy of electronic states



 $k_B T \ll \Delta < E_C$ 





#### Quantum dot = tunable artificial atom



L.P. Kouwenhoven, D.G.Austin & S. Tarucha Rep. Prog. Phys **64**, 701 (2001)





• Charge stability diagram



• Charge stability diagram (SET)





• Charge stability diagram (QD)



• Spectroscopy of excited states



experiment





#### Multiple quantum dots = artificial molecules

• Double quantum dot







## Molecular states in a double quantum dot

•

Weak coupling



Strong coupling: bonding and antibonding states Ε 2† detuning

# Fabrication of nanostructures and measurement techniques



## Fabrication of nanostructures: top-down vs. bottom-up approaches

Top-down

#### etched silicon nanowire (35 nm width)



#### MBE-grown InAs nanowires (40 nm diameter)







P. Caroff (IEMN)

## Fabrication of nanostructures: top-down vs. bottom-up approaches

- Top-down
  - easy integration
  - large variety of shapes
    BUT
  - defects due to the lithography process
  - sequential process (electron beam lihography)

- Bottom-up
  - defect free
  - highly parallel
  - often low cost
    - BUT
  - difficult integration
  - shapes defined by the process

#### often combine both!



#### Top-down approaches

• Litography (opitcal or electron beam)

Structure defined by etching



H. Linke et al., Phys. Rev. B 51, 15914 (2000)





#### Top-down approaches

• Litography (opitcal or electron beam)

# Structure defined by metal evaporation







#### Bottom-up approaches

• Semiconductor nanowires









P. Caroff (IEMN)

#### Bottom-up approaches

- Molecular electronics
  - carbon nanotubes
  - single molecules







J. Park et al., Nature 417, 722 (2002)

#### Quantum dots for electrical transport





#### Quantum dots for electronic transport

- Schottky contacts on a nanomaterial
  - easy to make
  - average tunability



- self-assembled quantum dot



C. Buizert et al., PRL 99, 136806 (2007)

 semiconductor nanowires and carbon nanotubes

#### Quantum dots for electronic transport

- Heterostructure
  - high reproducibility
  - controlled size
  - low tunability



#### longitudinal heterostructures in nanowires



M. Björk et al., Nano Lett. 4, 1621 (2004)

#### Quantum dots for electronic transport

- Local etching
  - very versatile
  - average tunability



#### - local etching of a nanowire



I. Shorubalko et al., Nano Lett. 8, 382 (2008)

#### Quantum dots for electronic transport - from planar heterostructures

- Local depletion
  - high complexity
  - high tunability





200 nm



- or nanowires





#### Contacts to the macroscopic world





Low temperature measurement



#### Low temperature measurement





#### Summary

- Part 1: Electronic transport in quantum nanostructures
  - Quantum effects can be observed on electronic transport for a sufficiently small size and at low temperature.
  - Electronic properties of small nanostructures (quantum dots) ressemble those of artificial atomes (or molecules)

